

Algemene informatie

Aanbesteding: Dielectric Etcher
Aanbestedende Dienst: Technische Universiteit Eindhoven
Referentie: PCM2026-10187RfP
Toelichting:
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Vraag en antwoord

Ref.nr. **Onderwerp:**
1 Wish 4

Vraag:
Request for Proposal, wish 4.

Antwoord:
Wish 4 has been changed by tenderer and is now as follows:

See for this wish number 6.8.7 in Chapter 6.8 of this Request for Proposal:
Uniformity of 3% in etch rate for a 600 nm etch depth across 4-inch wafers, with a 5 mm edge exclusion. This is of high importance, as production of Photonic Integrated Circuits comes with more stringent requirements. It is crucial to have homogeneous etch processes that can ensure better performing devices and higher yields.

This wish will be judged based on the by supplier offered homogeneity. Uniformity of 3% in etch rate for a 600 nm etch depth across 4-inch wafers, with a 5 mm edge exclusion will be judged with full 15 points, where a uniformity of 5% will be judged with 10 points.

Fase:
Inschrijffase

Inschrijfronde:
Inschrijfronde 1

Vragenronde:
Vragenronde 1

Beantwoord op:
15 okt 2026

Percelen:
P1 Dielectric Etcher